

**“Nanoscale materials characterization by combined Raman spectroscopy and scanning probe microscopies”**

**Picardi Gennaro**

**22/10/2014 Ecole Polytechnique**

**Rapporteurs :**

- Felidj Nordin, Professeur, UMR7086 Interfaces, Traitements, Organisation et Dynamique des Systèmes Université Paris Diderot Paris 7
- Hartschuh Achim, Professor, Ludwig-Maximilians-Universität München, Germany
- Melin Thierry, CR, UMR8520 Physique des Nanostructures et des Composants Quantiques, IEMN - Université Lille

**Examineurs :**

- De la Chapelle Marc Lamy, Professeur, UMR7244 Chimie, Structures, Propriétés de Biomatériaux et d'Agents Thérapeutiques, Université Paris Nord Paris 13
- Gucciardi Pietro Giuseppe, Dr., Istituto per i Processi Chimico Fisici Messina, Italy
- Boucaud Philippe, DR, Laboratoire de Physique Theorique d'Orsay, Université Paris
- Ossikovski Razvigor, Professeur, UMR7642 Physique des Interfaces et des Couches Minces, Ecole Polytechnique, Palaiseau

**Résumé :**

Characterization methods offering sub-diffraction limited (< 100 nm) spatial resolution are required for the understanding of the unique properties of materials at the nanoscale

and for further advancements in the domain of nanotechnologies. Coupling scanning probe microscopies (AFM, STM) with optical techniques give simultaneous access to topographical and detailed structural information at the same scale. In particular, examples of both classical and near-field (tip enhanced) Raman spectroscopy employed for strain determination in semiconducting nanostructures, determination of molecular excited states, chemical imaging of self-assembled monolayers are presented.